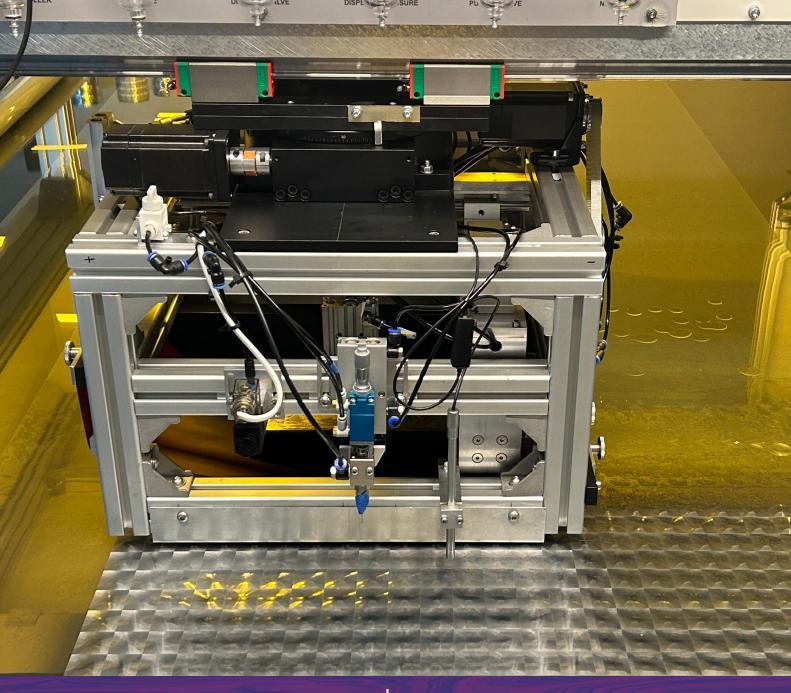


UV REPLICATION SYSTEMS

FOR NANO & MICRO STRUCTURES

UV Step & Repeat Recombination



www.xrdnano.com



- Precise alignment of Mask through mask aligner.
- Maximizes production efficiency with high-speed, continuous image replication.
- Step accuracy up to 1 micron.
- Accuracy from fixed origin <10 microns.
- Maximum unit cell = 380 x 380 mm.
- Maximum size of the bed 3000 x 1500 mm.
- Integrated or standalone UV Laminator to make copies of the master.
- +/- 90° head rotation for precise skew control.
- Vacuum bed.
- UV resin and consumable support.



Xr 600

Main technical features

600 Max Length of recombination in mm 600 Max width of recombination in mm Rubber nip Rubber roll out **Head Rotation** +/- 90° 100 x 100 mm Maximum single cell size in mm Maximum depth of replication in microns 20 +/- 0.005 Step accuracy in mm +/- 0.050 Accuracy from fixed origin in mm Software controlled Future enhancement in placement accuracy Software controlled Future enhancement in running accuracy 385 - 405 nm LED Wavelength 5 W/cm2 LED dosage Cycle 50/60 Hz 240 V/ 16 Amps Power



Xr 1650

Main technical features

1650 Max Length of recombination in mm 1000 Max width of recombination in mm Rubber nip Rubber roll out +/- 90° **Head Rotation** 200 x 200 mm Maximum single cell size in mm 20 Maximum depth of replication in microns +/- 0.010 Image placement accuracy in mm Running accuracy in mm +/- 0.150 Future enhancement in placement accuracy Software controlled Future enhancement in running accuracy Software controlled 385 - 405 nm LED Wavelength LED dosage 5 W/cm2 Cycle 50/60 Hz 240 V/ 16 Amps Power



Xr 1000

Main technical features

Max Length of recombination in mm	1000
Max width of recombination in mm	1000
Unwind cylinder	1
Rewind cylinder	1
Maximum single cell size in mm	125 x 125 mm
Maximum depth of replication in microns	20
Image placement accuracy in mm	+/- 0.010
Running accuracy in mm	+/- 0.150
Future enhancement in placement accuracy	Software controlled
Future enhancement in running accuracy	Software controlled
LED Wavelength	385 - 405 nm
LED dosage	5 W/cm2
Cycle	50/60 Hz
Power	240 V/ 16 Amps
I OWGI	2-10 V/ 10/1111p3

Our Vision:

To continuously innovate cutting-edge precision equipment and high-performance UV resins that empower authentication and holography converters, setting new benchmarks in quality, reliability, and technological advancement.

Design Philosophy:

No two pieces of our equipment will ever be the same. With each iteration, we are committed to improving the design, ensuring continuous innovation and enhanced performance with every new development.

Customization Expertise:

We specialize in developing all of our machines based on the key requirements of each individual client. Whether it's adapting to specific production environments, integrating unique features, or enhancing performance for specialized applications, our team is dedicated to delivering tailor-made solutions. Every machine we produce is designed with flexibility in mind, ensuring it meets the exact needs of the user while incorporating the latest technological advancements.

Evolution of Xr Design







2023



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